

ABSTRACT

A wiring structure includes wiring embedded in an insulating layer. A plurality of slit dummies each of that spaced each other are formed in the wiring. The wiring has a first portion that has a width wider than a reference width, and has a second portion that has a width shallower than the reference width. A distance of each slit dummy is less than a width of the reference width. The slit dummies are not formed in the second portion of the wiring.